

<b>Notice of References Cited</b>	Application/Control No. 09/995,187	Applicant(s)/Patent Under Reexamination CONNELL ET AL.	
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**NON-PATENT DOCUMENTS**

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	U	Sara et al., "Photolithography Fabrication of Sol-Gel Ridge Waveguide", SPIE Vol. 3469, July 1998, pages 118-123
	V	Coudray et al., "Integrated optics based on organo-mineral materials", European Materials Conference, June 1999
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.